



Cadence and Dassault Systèmes Expand Relationship for Greater Control and Management of Semiconductor Design Data

ENOVIA DesignSync Drives Global, Open Collaborative Design Environment for IP Development

LOWELL, Mass., September 13, 2011 – [Dassault Systèmes](#) (Euronext Paris: #13065, DSY.PA), a world leader in 3D and Product Lifecycle Management (PLM) solutions, announced today an expansion of its longstanding relationship with Cadence Design Systems. Designed to drive greater control and management of core product intellectual property (IP) during the development process, this collaboration enables integrated circuit (IC) designers within the Cadence Design Services team around the world to work more effectively.

“The delivery of high-quality IP requires close collaboration with design teams across geographies,” said Tim Henricks, vice president of design services for Cadence. “By implementing Dassault Systèmes’ ENOVIA DesignSync technology, we ensure tight collaboration between our R&D and Design services teams, enabling us to rapidly deploy integration-ready, differentiated IP. As a result, we allow customers to meet shrinking market windows in a predictable, profitable and productive way.”

ENOVIA Synchronicity DesignSync Data Manager allows Cadence resources to standardize on a collaborative design environment that spans multiple locations across the world. This relationship adds to the longtime inclusion of DesignSync within the Cadence design services team and continues more than 10 years of cooperation.

Rick Stanton, Director of Semiconductor Market Strategy, ENOVIA, Dassault Systèmes, comments, “Thanks to ENOVIA Synchronicity technology, Cadence design teams can access an open, production-proven system specifically designed for the global, collaborative development and management of core IP including complex IC design data. ENOVIA DesignSync has long supported the Open Access database standard and this partnership with Cadence reaffirms Dassault Systèmes commitment to openness and the value it brings to the thousands of common ENOVIA and Cadence users.”

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About Dassault Systèmes

As a world leader in 3D and Product Lifecycle Management (PLM) solutions, Dassault Systèmes brings value to more than 130,000 customers in 80 countries. A pioneer in the 3D software market since 1981, Dassault Systèmes applications provide a 3D vision of the entire lifecycle of products from conception to maintenance to recycling. The Dassault Systèmes portfolio consists of CATIA for designing the virtual product - DELMIA for virtual production - SIMULIA for virtual testing - ENOVIA for global collaborative lifecycle management, EXALEAD for search-based applications- SolidWorks for 3D mechanical design and 3DVIA for online 3D lifelike experiences. For more information, visit <http://www.3ds.com>.

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Dassault Systèmes Press Contacts

Derek Lane (NAM)	derek.lane@3ds.com	+1 (818) 673-2243
Elena Fernandez (LATAM)	elena.fernandez@3ds.com	+1 (978) 442-2790
Virginie Blindenberg (EMEA)	virginie.blindenber@3ds.com	+33 (0) 1 61 62 84 21
Namrata Gadhok (APAC)	namrata.gadhok@3ds.com	+91 (124) 457 7100
Mari Takaba (Japan)	mari.takaba@3ds.com	+81 3 5442 6675
Arnaud Malherbe (CORP/France)	arnaud.malherbe@3ds.com	+33 (0) 1 61 62 87 73